



United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/577,608	05/25/2000	Eigo Kawakami	862.C1917	6496
5514 75	590 04/20/2004		EXAMINER	
	K CELLA HARPER &	CHURCH, CRAIG E		
30 ROCKEFEL NEW YORK, 1			ART UNIT	
,			2882	
			B. H. B. L. L. B. B. C. G. G. G.	

DATE MAILED: 04/20/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

		W. 1				
	Application No.	Applicant(s)				
	09/577,608	KAWAKAMI ET AL.				
Office Action Summary	Examiner	Art Unit				
•	Craig E. Church	2882				
The MAILING DATE of this communication Period for Reply	appears on the cov r sheet w	ith the correspondence address				
A SHORTENED STATUTORY PERIOD FOR RE THE MAILING DATE OF THIS COMMUNICATIO - Extensions of time may be available under the provisions of 37 CFI after SIX (6) MONTHS from the mailing date of this communication - If the period for reply specified above is less than thirty (30) days, a - If NO period for reply is specified above, the maximum statutory pe - Failure to reply within the set or extended period for reply will, by st Any reply received by the Office later than three months after the mearned patent term adjustment. See 37 CFR 1.704(b).	ON. R 1.136(a). In no event, however, may a in the statutory minimum of thire strong within the statutory minimum of thire strong will apply and will expire SIX (6) MON that the cause the application to become Africans.	reply be timely filed ty (30) days will be considered timely. NTHS from the mailing date of this communication. BANDONED (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on 2	<u> 2004</u> .					
2a)⊠ This action is FINAL . 2b)□	↑ This action is FINAL . 2b) This action is non-final.					
3) Since this application is in condition for all	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is					
closed in accordance with the practice und	closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims						
•	Claim(s) <u>1-20,22-25 and 27-31</u> is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration.					
5) Claim(s) is/are allowed.						
6)⊠ Claim(s) <u>1-20,22-25,27-31</u> is/are rejected.						
7) Claim(s) is/are objected to.						
8) Claim(s) are subject to restriction ar	nd/or election requirement.					
Application Papers						
9) The specification is objected to by the Exan	niner.					
10) The drawing(s) filed on is/are: a)	accepted or b) ☐ objected to	by the Examiner.				
Applicant may not request that any objection to	the drawing(s) be held in abeyar	nce. See 37 CFR 1.85(a).				
Replacement drawing sheet(s) including the co	•	• •				
11)☐ The oath or declaration is objected to by the	e Examiner. Note the attache	d Office Action or form PTO-152.				
Priority under 35 U.S.C. § 119						
 12) Acknowledgment is made of a claim for fore a) All b) Some * c) None of: 1. Certified copies of the priority document 2. Certified copies of the priority document 	nents have been received.					
3. Copies of the certified copies of the						
application from the International Bu	•	· ·				
* See the attached detailed Office action for a	list of the certified copies not	received.				
Attachment(s)						
1) Notice of References Cited (PTO-892)	4) Interview	Summary (PTO-413)				
2) Notice of Draftsperson's Patent Drawing Review (PTO-948) Paper No(s)/Mail Date				
 Information Disclosure Statement(s) (PTO-1449 or PTO/SE Paper No(s)/Mail Date 	6) Other:	Informal Patent Application (PTO-152) —				

Art Unit: 2882

The following is a quotation of the first paragraph of 35 U.S.C. 112:

The specification shall contain a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to make and use the same and shall set forth the best mode contemplated by the inventor of carrying out his invention.

Claims 1-31 are rejected under 35 U.S.C. 112, first paragraph, because the specification, while being enabling for substituting nitrogen and helium in an x-ray lithography exposure chamber, does not reasonably provide enablement for any gases in any environment as claimed. The specification does not enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to practice the invention commensurate in scope with these claims. As an example, corrosive gas such as nitrous oxide would easily damage the recited static pressure bearing. The specification (lines 1-10 of page 8) states that the invention is directed to x-ray lithography, and it is recommended that the scope of the claims be so limited.

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United

Art Unit: 2882

States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

Claims 1-5, 7, 8, 12, 13, 16-20 and 22-25 are rejected under 35 U.S.C. 102(e) as being anticipated by Hara et al (6616898). Hara teaches x-ray lithography apparatus comprising (see especially figures 5 and 9) a synchrotron x-ray source (lines 16-20 of column 14); a sealed chamber 1; a mask 5 and mask holder 6 in the chamber; a substrate 2 and substrate chuck 3 in the chamber; static pressure bearings 10 within the chamber for positioning the substrate; means 24 and 14 for supplying helium to the chamber; means 13, 62, 61 and etc for providing helium directly to the static pressure bearings; gas recirculation system comprising chamber inlet orifice 15, outlet orifice 16, pump 20, buffer tank 26 and flow rate control 27; means 64 (83) for supplying nitrogen to the chamber and control means 22, sensor 23 and various valves for withdrawing a first gas (nitrogen) from the chamber and replacing it with a second gas (helium). Lines 26-57 of column 28 explain that when the lithography apparatus is to be shut down as for maintenance, the helium is withdrawn from the chamber and shored in tank 26 after which the chamber is filled with nitrogen from line 83 (or tank 64). When the apparatus is to be restarted, nitrogen is withdrawn from the chamber by pump 20, and the chamber is refilled with helium from tanks 24 and 62.

Claims 6, 9-11, 14, 15, 21 and 26-31 would be allowable if rewritten to overcome the rejection(s) under 35 U.S.C. 112, set forth in this Office action and to include all of the limitations of the base claim and any intervening claims.

Application/Control Number: 09/577,608

Art Unit: 2882

Any inquiry concerning this communication should be directed to Craig E. Church at telephone number (571) 272-2488.

Croig & Church

Craig E. Church Senior Examiner Art Unit 2882